

T Gregorkiewicz

List of Publications by Year in descending order

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153
times ranked

2231
citing authors

#	ARTICLE	IF	CITATIONS
1	Hot-carrier-mediated impact excitation of Er ³⁺ ions in SiO ₂ sensitized by Si Nanocrystals. Applied Physics Letters, 2018, 113, 031109.	1.5	11
2	High-Power Eu-Doped GaN Red LED Based on a Multilayer Structure Grown at Lower Temperatures by Organometallic Vapor Phase Epitaxy. MRS Advances, 2017, 2, 159-164.	0.5	18
3	Trapping time of excitons in Si nanocrystals embedded in a SiO_2 matrix. Physical Review B, 2017, 95, .	1.1	5
4	Strong infrared photoluminescence in highly porous layers of large faceted Si crystalline nanoparticles. Scientific Reports, 2016, 6, 25664.	1.6	11
5	Step-like increase of quantum yield of 1.5 μm Er-related emission in SiO ₂ doped with Si nanocrystals. Journal of Applied Physics, 2015, 117, 064303.	1.1	1
6	Generation of hot carriers for photon management in future photovoltaics. Solar Energy Materials and Solar Cells, 2015, 135, 67-71.	3.0	6
7	Silicon quantum dots: surface matters. Journal of Physics Condensed Matter, 2014, 26, 173201.	0.7	163
8	Efficient optical extraction of hot-carrier energy. Nature Communications, 2014, 5, 4665.	5.8	42
9	Enhancement of luminescence quantum yield of 1.5 μm emission from Er-doped SiO ₂ sensitized with Si nanocrystals. Materials Research Society Symposia Proceedings, 2014, 1592, 1.	0.1	0
10	Optical excitation and external photoluminescence quantum efficiency of Eu ³⁺ in GaN. Scientific Reports, 2014, 4, 5235.	1.6	33
11	Carrier dynamics in Si nanocrystals in an SiO ₂ matrix investigated by transient light absorption. Physical Review B, 2013, 88, .	1.1	17
12	Thermally Activated Emission from Direct Bandgap-Like Silicon Quantum Dots. ECS Journal of Solid State Science and Technology, 2013, 2, R97-R99.	0.9	6
13	Manipulating Photon Energy with Si Nanocrystals. , 2012, , .		0
14	Si nanocrystals for photon management. , 2012, , .		0
15	Investigation of saturation and excitation behavior of 1.5 μm emission from Er ³⁺ ions in SiO ₂ sensitized with Si nanocrystals. Physica Status Solidi C: Current Topics in Solid State Physics, 2012, 9, 2312-2317.	0.8	3
16	Self-trapped exciton state in Si nanocrystals revealed by induced absorption. Physical Review B, 2012, 85, .	1.1	22
17	Increased carrier generation rate in Si nanocrystals in SiO ₂ investigated by induced absorption. Applied Physics Letters, 2011, 99, .	1.5	19
18	Step-like enhancement of luminescence quantum yield of silicon nanocrystals. Nature Nanotechnology, 2011, 6, 710-713.	15.6	186

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19	Evaluation of free carrier losses to $1.54\mu\text{m}$ emission in Si/Si:Er nanolayers on SOI substrate for optical gain observation. <i>Optical Materials</i> , 2011, 33, 1094-1096.	1.7	2
20	Fast dynamics of $1.5\mu\text{m}$ photoluminescence in Er-doped SiO ₂ sensitized with Si nanocrystals. <i>Optical Materials</i> , 2011, 33, 1091-1093.	1.7	0
21	Optical gain of fast $1.5\mu\text{m}$ emission in Er-doped SiO ₂ sensitized by Si nanocrystals. <i>Optical Materials</i> , 2011, 33, 1094-1096.	1.1	9
22	Photon cutting for excitation of Er ³⁺ ions in SiO ₂ sensitized by Si quantum dots. <i>Physical Review B</i> , 2011, 84, .	1.1	15
23	Saturation of luminescence from Si nanocrystals embedded in SiO ₂ . <i>Physica Status Solidi (A) Applications and Materials Science</i> , 2010, 207, 183-187.	0.8	27
24	Direct bandgap optical transitions in Si nanocrystals. <i>JETP Letters</i> , 2010, 90, 758-762.	0.4	59
25	Red spectral shift and enhanced quantum efficiency in phonon-free photoluminescence from silicon nanocrystals. <i>Nature Nanotechnology</i> , 2010, 5, 878-884.	15.6	294
26	Optical gain of the $1.54\mu\text{m}$ emission in MBE-grown Si:Er nanolayers. <i>Physical Review B</i> , 2010, 81, .	1.1	2
27	Terahertz electromagnetic transitions observed within the $415/2$ ground multiplet of Er ³⁺ ions in Si. <i>Physical Review B</i> , 2009, 79, .	1.7	4
28	Space-separated quantum cutting in differently prepared solid-state dispersions of Si nanocrystals and Er ³⁺ ions in SiO ₂ . <i>Materials Science and Engineering B: Solid-State Materials for Advanced Technology</i> , 2009, 159-160, 87-89.	1.3	0
29	Optical properties of Si/Si:Er multi-nanolayer structures grown by SMBE method. <i>Physica B: Condensed Matter</i> , 2009, 404, 5132-5135.	1.7	8
30	Optical spectroscopy of carrier relaxation processes in Si nanocrystals. <i>Materials Science and Engineering B: Solid-State Materials for Advanced Technology</i> , 2009, 159-160, 190-193.	1.3	0
31	On relation between the $1.5\mu\text{m}$ Er-related emission and $9\mu\text{m}$ vibrational modes of oxygen in silicon. <i>Physica E: Low-Dimensional Systems and Nanostructures</i> , 2009, 41, 1052-1054.	0.3	1
32	Excitation efficiency and saturation dynamics of near-infrared emission from Si nanocrystals embedded in a SiO ₂ -matrix. <i>Journal of Physics: Conference Series</i> , 2009, 165, 012018.	1.7	0
33	Pump-probe investigations of THz transitions in Si/Si:Er ³⁺ nanolayers. <i>Materials Science and Engineering B: Solid-State Materials for Advanced Technology</i> , 2008, 146, 160-162.	1.7	0
34	Mid-infrared spectroscopy of the Er-related donor state in Si/Si:Er ³⁺ nanolayers. <i>Materials Science and Engineering B: Solid-State Materials for Advanced Technology</i> , 2008, 146, 131-134.	15.6	302
35	Space-separated quantum cutting with silicon nanocrystals for photovoltaic applications. <i>Nature Photonics</i> , 2008, 2, 105-109.	1.7	0
36	Energy transfer in Er-doped SiO ₂ with Si nanocrystals. <i>Physical Review B</i> , 2008, 78, .		

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37	Microscopic evidence for role of oxygen in luminescence of Er ³⁺ ions in Si: Two-color and pump-probe spectroscopy. <i>Physical Review B</i> , 2008, 78, .	1.1	10
38	Concentration of Er ³⁺ ions contributing to 1.54 μ m emission in Si ^{1-x} Si ₃ N ₄ :Er nanolayers. <i>Physical Review B</i> , 2007, 76, .	1.1	21
39	Donor-State-Enabling Er-Related Luminescence in Silicon: Direct Identification and Resonant Excitation. <i>Physical Review Letters</i> , 2007, 99, 077401.	2.9	29
40	Non-radiative sub-microsecond recombination of excited Er ³⁺ ions in SiO ₂ sensitized with Si nanocrystals. <i>Physica E: Low-Dimensional Systems and Nanostructures</i> , 2007, 38, 144-147.	1.3	7
41	1.54 μ m Si:Er light emitting diode with memory function. <i>Applied Physics Letters</i> , 2006, 88, 201101.	1.5	4
42	On optical activity of Er ³⁺ ions in Si-rich SiO ₂ waveguides. <i>Applied Physics Letters</i> , 2006, 89, 171908.	1.5	15
43	Nanosecond Dynamics of the Near-Infrared Photoluminescence of Er-Doped SiO ₂ Sensitized with Si Nanocrystals. <i>Physical Review Letters</i> , 2006, 97, 207401.	2.9	87
44	Isotope Dependence of the Lifetime of the 1136 cm^{-1} Vibration of Oxygen in Silicon. <i>Physical Review Letters</i> , 2006, 96, 225503.	2.9	34
45	Photoluminescence excitation spectroscopy of erbium in epitaxially grown Si:Er structures. <i>Optical Materials</i> , 2005, 27, 890-893.	1.7	9
46	Erbium Photoluminescence Excitation Spectroscopy in Si : Er Epitaxial Structures. <i>Physics of the Solid State</i> , 2005, 47, 86.	0.2	3
47	Erbium Excitation in a SiO ₂ : Si-nc Matrix under Pulsed Pumping. <i>Physics of the Solid State</i> , 2005, 47, 110.	0.2	1
48	The Auger process of luminescence quenching in Si/Si:Er multilayers. <i>Journal of Physics Condensed Matter</i> , 2005, 17, S2191-S2195.	0.7	7
49	Theoretical modeling of thermally activated luminescence quenching processes in Si:Er. <i>Physical Review B</i> , 2005, 72, .	1.1	15
50	Terahertz modulation of the blue photoluminescence in ZnSe. <i>Physical Review B</i> , 2005, 72, .	1.1	7
51	Time-resolved free-electron laser spectroscopy of a copper isoelectronic center in silicon. <i>Physical Review B</i> , 2005, 71, .	1.1	8
52	On 2.7 μ m Emission from Er-doped Large Bandgap Hosts. <i>Materials Research Society Symposia Proceedings</i> , 2005, 866, 7.	0.1	6
53	Sensitization of Er luminescence by Si nanoclusters. <i>Physical Review B</i> , 2004, 69, .	1.1	131
54	Optical properties of a single type of optically active center in Si ^{1-x} Si ₃ N ₄ :Er nanostructures. <i>Physical Review B</i> , 2004, 70, .	1.1	33

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55	Terahertz-assisted excitation of the 1.5 μ m photoluminescence of Er in crystalline Si. <i>Physical Review B</i> , 2004, 70, .	1.1	6
56	Er ³⁺ photoluminescence excitation spectra in erbium-doped epitaxial silicon structures. <i>Physics of the Solid State</i> , 2004, 46, 97-100.	0.2	11
57	Photoluminescence and excitation spectroscopy of the 1.5 μ m Er-related band in MBE-grown GaN layers. <i>Superlattices and Microstructures</i> , 2004, 36, 701-705.	1.4	5
58	Excitation paths in RE-doped III-V semiconductors. <i>Materials Science and Engineering B: Solid-State Materials for Advanced Technology</i> , 2003, 105, 141-145.	1.7	12
59	Spectroscopic characterization of Er-1 center in selectively doped silicon. <i>Materials Science and Engineering B: Solid-State Materials for Advanced Technology</i> , 2003, 105, 150-152.	1.7	0
60	Two-color mid-infrared spectroscopy of optically doped semiconductors. <i>Journal of Luminescence</i> , 2003, 102-103, 85-90.	1.5	8
61	Silicon-based all-optical memory elements for 1.54 μ m photonics. <i>Solid-State Electronics</i> , 2003, 47, 165-168.	0.8	4
62	Photoluminescence quenching in InP:Yb with a free-electron laser. <i>Applied Surface Science</i> , 2003, 208-209, 23-26.	3.1	1
63	Magneto-optical study of Er ³⁺ -related center in selectively doped Si:Er. <i>Physica E: Low-Dimensional Systems and Nanostructures</i> , 2003, 16, 544-546.	1.3	4
64	Optical properties of a silver-related defect in silicon. <i>Physical Review B</i> , 2003, 67, .	1.1	15
65	Microscopic Structure of Er-Related Optically Active Centers in Crystalline Silicon. <i>Physical Review Letters</i> , 2003, 90, 066401.	2.9	50
66	Auger deexcitation of Er ³⁺ ions in crystalline Si optically induced by midinfrared illumination. <i>Physical Review B</i> , 2003, 68, .	1.1	15
67	Microscopic model for nonexcitonic mechanism of 1.5 μ m photoluminescence of the Er ³⁺ ion in crystalline Si. <i>Physical Review B</i> , 2003, 67, .	1.1	19
68	Si Nanocrystals as Sensitizers for Er PL in SiO ₂ . <i>Materials Research Society Symposia Proceedings</i> , 2003, 770, 691.	0.1	2
69	Optically Induced Deexcitation of Rare-Earth Ions in a Semiconductor Matrix. <i>Physical Review Letters</i> , 2002, 89, 227401.	2.9	71
70	Afterglow effect in photoluminescence of Si:Er. <i>Physical Review B</i> , 2002, 65, .	1.1	28
71	Time-resolved investigation of the mid-infrared-induced enhancement of Er ³⁺ emission in Si. <i>Physica B: Condensed Matter</i> , 2001, 308-310, 337-339.	1.3	0
72	Observation of Zeeman effect in photoluminescence of Er ³⁺ ion imbedded in crystalline silicon. <i>Physica B: Condensed Matter</i> , 2001, 308-310, 340-343.	1.3	18

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73	Erbium excitation across the bulk of silicon wafer: an effect of p-n junction at Si/Si:Er interface. <i>Physica B: Condensed Matter</i> , 2001, 308-310, 357-360.	1.3	0
74	Optically induced Auger recombination of Yb ³⁺ in p-type InP. <i>Physica B: Condensed Matter</i> , 2001, 308-310, 884-887.	1.3	3
75	Photoluminescence from Si:Er under front and backside excitation. <i>Materials Science and Engineering B: Solid-State Materials for Advanced Technology</i> , 2001, 81, 59-61.	1.7	3
76	Mid-infrared induced quenching of photoluminescence in Si:Er. <i>Materials Science and Engineering B: Solid-State Materials for Advanced Technology</i> , 2001, 81, 80-82.	1.7	0
77	Semiconductors: Rare Earth Impurities. , 2001, , 8392-8396.		0
78	Free-electron laser studies of energy transfer mechanisms in semiconductors doped with transition series ions. <i>Journal of Luminescence</i> , 2001, 94-95, 243-248.	1.5	8
79	Influence of p-n junction formation at a Si/Si:Er interface on low-temperature excitation of Er ³⁺ ions in crystalline silicon. <i>Physical Review B</i> , 2001, 64, .	1.1	4
80	Excitation cross section of erbium in semiconductor matrices under optical pumping. <i>Physical Review B</i> , 2001, 64, .	1.1	51
81	780-meV photoluminescence band in silver-doped silicon: Isotope effect and time-resolved spectroscopy. <i>Physical Review B</i> , 2001, 65, .	1.1	8
82	Tracking recombination processes in Si : Er with a free-electron laser. <i>Journal of Luminescence</i> , 2000, 87-89, 96-100.	1.5	0
83	Hydrogen passivation of the selenium double donor in silicon: A study by magnetic resonance. <i>Physical Review B</i> , 2000, 61, 7448-7458.	1.1	7
84	Photoluminescence of erbium-doped silicon: Excitation power and temperature dependence. <i>Journal of Applied Physics</i> , 2000, 88, 1443-1455.	1.1	24
85	Energy transfer between shallow centers and rare-earth ion cores: Er ³⁺ ion in silicon. <i>Physical Review B</i> , 2000, 61, 5369-5375.	1.1	36
86	Lasing in Rare-Earth-Doped Semiconductors: Hopes and Facts. <i>MRS Bulletin</i> , 1999, 24, 27-32.	1.7	21
87	Direct spectral probing of energy storage in Si:Er by a free-electron laser. <i>Applied Physics Letters</i> , 1999, 75, 4121-4123.	1.5	28
88	Atomic and electronic structure of hydrogen-passivated double selenium donors in silicon. <i>Physica B: Condensed Matter</i> , 1999, 273-274, 239-242.	1.3	2
89	Spectroscopic probing of defect-related energy storage in silicon doped with erbium. <i>Physica B: Condensed Matter</i> , 1999, 273-274, 326-329.	1.3	1
90	The photoluminescence mechanism of erbium in silicon: intensity dependence on excitation power and temperature. <i>Physica B: Condensed Matter</i> , 1999, 273-274, 338-341.	1.3	2

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91	Role of Shallow Bound States in Emission Processes of Rare-Earth Doped Semiconductors. <i>Physica Status Solidi (B): Basic Research</i> , 1998, 210, 737-745.	0.7	9
92	Excitation mechanism of Er in Si studied with a free-electron laser. <i>Journal of Luminescence</i> , 1998, 80, 291-295.	1.5	2
93	Direct Observation of the Two-Stage Excitation Mechanism of Er in Si. <i>Physical Review Letters</i> , 1998, 81, 4748-4751.	2.9	46
94	Shallow thermal donors associated with H, Al and N in annealed Czochralski silicon distinguished by infrared spectroscopy. <i>Semiconductor Science and Technology</i> , 1997, 12, 1404-1408.	1.0	15
95	Electron-paramagnetic-resonance study of silver-induced defects in silicon. <i>Physical Review B</i> , 1997, 56, 4614-4619.	1.1	8
96	Copper-related defects in silicon: Electron-paramagnetic-resonance identification. <i>Physical Review B</i> , 1997, 56, 4620-4625.	1.1	15
97	Photoluminescence Study of Erbium in Silicon with a Free-Electron Laser. <i>Materials Science Forum</i> , 1997, 258-263, 1497-1502.	0.3	2
98	High-Field EPR Spectroscopy of Thermal Donors in Silicon. <i>Materials Science Forum</i> , 1997, 258-263, 373-378.	0.3	6
99	The 4f Intrashell Transitions of Ytterbium in Indium Phosphide. <i>Materials Research Society Symposia Proceedings</i> , 1996, 422, 161.	0.1	2
100	Excitation and DE-Excitation of Yb ³⁺ in Inp and Er ³⁺ in Si: Photoluminescence and Impact Ionization Studies. <i>Materials Research Society Symposia Proceedings</i> , 1996, 422, 207.	0.1	10
101	Magnetic resonance spectroscopy of hydrogen-passivated double donors in silicon. <i>Materials Science and Engineering B: Solid-State Materials for Advanced Technology</i> , 1996, 36, 138-141.	1.7	4
102	Infrared absorption in silicon from shallow thermal donors incorporating hydrogen and a link to the NL10 paramagnetic resonance spectrum. <i>Physical Review B</i> , 1996, 54, R6803-R6806.	1.1	49
103	Magnetic Resonance Investigations of Thermal Donors in Silicon. , 1996, , 61-82.		4
104	Magnetic resonance spectroscopy of hydrogen-passivated double donors in silicon. , 1996, , 138-141.		0
105	Endor Identification of a Hydrogen-Passivated Thermal Donor. <i>Materials Science Forum</i> , 1995, 196-201, 849-854.	0.3	12
106	Role of electron traps in the excitation and deâ€œexcitation mechanism of Yb ³⁺ in InP. <i>Journal of Applied Physics</i> , 1995, 77, 1523-1530.	1.1	8
107	Electron paramagnetic resonance versus spin-dependent recombination: Excited triplet states of structural defects in irradiated silicon. <i>Physical Review B</i> , 1995, 52, 1144-1151.	1.1	49
108	Role of Hydrogen in the Formation and Structure of the Si- NL10 Thermal Donor. <i>Physical Review Letters</i> , 1995, 74, 2030-2033.	2.9	57

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109	Electron-paramagnetic-resonance identification of hydrogen-passivated sulfur centers in silicon. <i>Physical Review B</i> , 1995, 51, 16746-16749.	1.1	17
110	Hydrogen Passivation of the Sulfur Double Donor in Silicon Investigated by EPR and ENDOR. <i>Materials Science Forum</i> , 1995, 196-201, 855-860.	0.3	4
111	Photoluminescence measurements on erbium-doped silicon. <i>Semiconductor Science and Technology</i> , 1995, 10, 666-671.	1.0	9
112	Photoluminescence Study of the 779-meV Band in Silver-Doped Silicon. <i>Materials Science Forum</i> , 1994, 143-147, 755-760.	0.3	2
113	Stallinga, Gregorkiewicz, and Ammerlaan Reply. <i>Physical Review Letters</i> , 1994, 73, 1457-1457.	2.9	6
114	EPR spectroscopy of platinum-hydrogen complexes in silicon. <i>Physical Review B</i> , 1994, 49, 13423-13429.	1.1	30
115	Electron paramagnetic resonance study of the NL51 spectrum in hydrogen-implanted silicon. <i>Solid State Communications</i> , 1994, 90, 401-404.	0.9	12
116	Electron paramagnetic resonance of molecular hydrogen in silicon. <i>Physical Review Letters</i> , 1993, 71, 117-120.	2.9	32
117	Photoluminescence of silicon thermal donors. <i>Physical Review B</i> , 1993, 47, 7005-7012.	1.1	21
118	Magnetic resonance spectroscopy in silver-doped silicon. <i>Journal of Applied Physics</i> , 1993, 73, 1797-1801.	1.1	13
119	A New Bistable Shallow Thermal Donor in Al-Doped Si. <i>Materials Science Forum</i> , 1993, 143-147, 1185-1190.	0.3	7
120	Trapping of Molecular Hydrogen in Porous Silicon and at Si/SiO ₂ Interfaces and a Possible Reinterpretation of the Pb Center. <i>Materials Research Society Symposia Proceedings</i> , 1993, 324, 385.	0.1	0
121	Excitation and De-Excitation Mechanisms of Rare-Earth Ions in III-V Compounds: Optically Detected Microwave-Induced Impact Ionization of Yb Dopant in Inp. <i>Materials Research Society Symposia Proceedings</i> , 1993, 301, 239.	0.1	4
122	Silicon Thermal Donors: Photoluminescence and Magnetic Resonance Study of Boron- and Aluminum-Doped Silicon. <i>Materials Science Forum</i> , 1992, 83-87, 407-412.	0.3	2
123	Paramagnetic state of the isolated gold impurity in silicon. <i>Physical Review Letters</i> , 1992, 69, 3185-3188.	2.9	19
124	Electron-paramagnetic-resonance identification of silver centers in silicon. <i>Physical Review B</i> , 1992, 46, 4544-4550.	1.1	27
125	Sensitive electron paramagnetic resonance spectrometer for studying defects in semiconductors. <i>Review of Scientific Instruments</i> , 1992, 63, 5742-5749.	0.6	8
126	Photoluminescence studies on thermal donors in boron- and aluminum-doped silicon. <i>Physical Review B</i> , 1992, 46, 2034-2040.	1.1	11

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127	High-resolution EPR spectroscopy of the Si-NL10 thermal donor. <i>Physical Review B</i> , 1992, 45, 5873-5878.	1.1	3
128	Aluminum incorporation in the Si-NL10 thermal donor. <i>Physical Review B</i> , 1992, 46, 4582-4589.	1.1	7
129	High-field EPR spectroscopy of thermal donors in silicon. <i>Physica B: Condensed Matter</i> , 1992, 177, 476-480.	1.3	1
130	Nuclear interactions of defects in semiconductors – magnetic resonance measurements. <i>Nuclear Instruments & Methods in Physics Research B</i> , 1992, 63, 154-162.	0.6	4
131	Infrared Absorption Study of Thermally Generated Shallow Donor Centers in Czochralski Silicon. <i>Acta Physica Polonica A</i> , 1992, 82, 677-680.	0.2	2
132	Optically detected microwave-induced impact ionization of ytterbium bound excitons in InP. <i>Applied Physics Letters</i> , 1991, 58, 2237-2239.	1.5	25
133	Optically detected Auger recombinations in erbium- and ytterbium-doped InP. <i>Applied Physics Letters</i> , 1991, 59, 3279-3281.	1.5	9
134	Magnetic-resonance studies of interstitial Mn in GaP and GaAs. <i>Physical Review B</i> , 1991, 44, 3012-3019.	1.1	28
135	Characterization of Defect Centres in Semiconductors by Advanced ENDOR Techniques. <i>Acta Physica Polonica A</i> , 1991, 80, 161-170.	0.2	3
136	Thermal Donor Generation in Boron- and Aluminium-Doped Czochralski Silicon. <i>Acta Physica Polonica A</i> , 1991, 80, 345-348.	0.2	3
137	Magnetic resonance spectroscopy of zinc doped silicon. <i>Solid State Communications</i> , 1990, 75, 115-120.	0.9	13
138	Metastable thermal donor states in germanium: Identification by electron paramagnetic resonance. <i>Physical Review B</i> , 1990, 42, 9802-9809.	1.1	16
139	Comparative study of Si-NL8 and Si-NL10 thermal-donor-related EPR centers. <i>Physical Review B</i> , 1990, 41, 12628-12636.	1.1	33
140	Silicon electron-nuclear double-resonance study of the NL10 heat-treatment center. <i>Physical Review B</i> , 1989, 39, 1648-1658.	1.1	12
141	Thermal donors and oxygen-related complexes in silicon. <i>Materials Science and Engineering B: Solid-State Materials for Advanced Technology</i> , 1989, 4, 291-297.	1.7	8
142	Si-NL10: Paramagnetic Acceptor State of the Silicon Thermal Donor. <i>Physical Review Letters</i> , 1988, 61, 227-230.	2.9	22
143	Microscopic structure of the NL10 heat-treatment center in silicon: Study by electron-nuclear double resonance. <i>Physical Review B</i> , 1988, 38, 3998-4015.	1.1	47
144	Transition metal impurities in silicon. , 1988, , 244-261.		4

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145	Photoluminescence on oxygen-rich acceptor-doped silicon. Journal of Physics C: Solid State Physics, 1987, 20, 2183-2191.	1.5	5
146	Electron paramagnetic resonance study of heat treatment centers in n-type silicon. Journal of Applied Physics, 1987, 62, 4404-4405.	1.1	19
147	EPR studies of heat-treatment centers in p-type silicon. Physical Review B, 1987, 35, 3810-3817.	1.1	49
148	Oxygen incorporation in thermal-donor centers in silicon. Physical Review Letters, 1987, 59, 1702-1705.	2.9	28
149	Spin delocalization of interstitial iron in silicon. Physical Review B, 1986, 34, 4511-4520.	1.1	13
150	Oxygen related mechanism of reverse annealing for boron implants in silicon. Radiation Effects, 1984, 85, 249-254.	0.4	2
151	Electron paramagnetic resonance of silicon implanted with boron and arsenic ions. Radiation Effects, 1983, 77, 195-203.	0.4	1
152	EPR studies of the annealing of damage produced by boron implantation of silicon single crystals. Radiation Effects, 1982, 68, 69-76.	0.4	1